650nm Accurate Wavelength Laser System of AWS Series



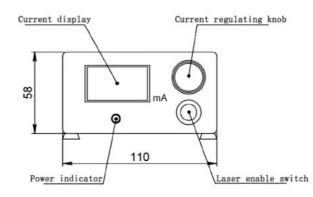
DESCRIPTION

Our company has specially developed 650nm spatial output semiconductor light source for optical experiment and particle size measurement application. It has passed industrial design and batch production. The product has the advantages of compact structure, stable power, portable operation, etc., and meets the teaching and research and development needs of universities and scientific research institutions.

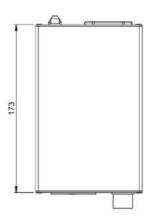
FEATURES

- Small and compact system
- Includes slow-start, short-circuit protection

Model		CL650-SOW-5mW-AWS002 CL650-SIF(FP)-2mW-AWS003	
Optical Parameter	Central Wavelength (nm)	650	650
	Wavelength Tolerance (nm)	±5	±5
	Output Power (mW)	5	2
	Spot size (mm)	1.2 x 2.4	/
	Extinction ratio	100:1	/
	Line width (nm)	1	1
	Power stability	±1.5% @8H	±1.5% @8H
	Divergence angle (mrad)	0.4 x 0.2	/
System Parameter	Power Adjustment Range	0~100%	0~100%
	Preheat Time (Min)	15	15
	Output Method	Spatial output	FC/PC
	Adapted Fiber	/	3.5µm, 0.14NA
	Power Input	100-200VAC, 50/60Hz	
	System Power Consumption (W)		<2
	Storage Humidity (RH)	0~80%	
	Storage Temperature (°C)	-10~60	
	Operating Temperature ($^{\circ}$ C)	10~35	
	System Weight (Kg)		2
	Laser Head Size (mm)	45 x 30 x 120	/
	Laser Power Size (mm)	110×58×173	110×58×173



Front view of laser power supply



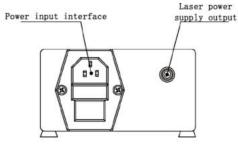
Top view of laser power supply Note: The built-in laser system does not include a laser head





APPLICATIONS

- Holographic detection
- Granularity measurement
- Laser guidance
- Optical experiment



- Rear view of laser power supply

